

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	915	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmso or "c. sub.2h.sub.6os") near10 (HPLC or pressure near2 liquid adj chromatography)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:51
L2	1	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmso or "c. sub.2h.sub.6os") near10 (HPLC or pressure near2 liquid adj chromatography) same (photoresist or resist or mask)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:51
L3	82	(photoresist or resist or mask\$4) same (dimethylsulfoxide or dimethyl\$1sulfoxide or dmso or "c. sub.2h.sub.6os") same etch\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:51
L4	10	(photoresist or resist or mask\$4) same (dimethylsulfoxide or dimethyl\$1sulfoxide or dmso or "c. sub.2h.sub.6os") same (grad\$3 or hplc)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:51
L5	27	hard near2 mask near10 (sio2 or "sio.sub.2" or silicon adj dioxide or silicon adj oxide) same (photoresist or resist) same dielectric same (ash\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:51
L6	68	(photo near resist or resist or photoresist) same ultrasonic near10 (improv\$4 or advantag\$5 or prefer\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:52
L7	43	low near2 dielectric near2 (layer or film) same hard near2 mask same (photo\$1resist\$5) same (strip\$6)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:52
L8	79	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmso or "c. sub.2h.sub.6os") near20 (photo\$1resist)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:52
L9	10	(dimethylsulfoxide or dimethyl\$1sulfoxide or dmso or "c. sub.2h.sub.6os") near10 (remov\$5 or strip\$5) near10 selectiv\$5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:52

L10	221	john near2 lang.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:52
L11	10	john near2 lang.in. and (photo\$1resist or resist)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:54
L12	11	john near2 lang.in. and (dmso or dimethyl)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:55
L13	1	john near2 lang.in. and (dmso or dimethyl near2 sulfoxide or dimethylsulfoxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/08 14:54